Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L2	2	("6780250").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/08 08:20
L3	258893	(remov$3 or stripp$3 or etch$3) same oxide	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/08 08:22
L4	333	L3 same ((transfer$3 or load adj lock) near chamber)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/08 08:22
L5	226	L4 same (wafer or semiconductor)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/08 08:22
L6	226	L4 same (wafer or semiconductor)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/08 08:23
L7	32	L6 same ((vapor$3 near solution) or (hydrofluoric or "HF"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/08 08:23